

# BEST AVAILABLE COPY

PATENT NUMBER and  
ISSUE DATE

## U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10072102	02/08/2002	430	311	456 452	Duda

**\*\*APPLICANTS:** Ang Chew-Hoe; Lim Eng; Cha Randall; Zheng Jia-Zhen; Quek Elgin;  
Zhou Mei-Sheng; Yen Daniel;

**\*\*CONTINUING DATA VERIFIED:**

**\*\* FOREIGN APPLICATIONS VERIFIED:**

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed	<input type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO
35 USC 119 conditions met	<input type="checkbox"/> yes <input type="checkbox"/> no	CS01-027
Verified and Acknowledged Examiner's initials		

**TITLE :** Method to pattern small features by using a re-flowable hard mask

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims	Print Claim for O.G
Assistant Examiner		<b>DRAWING</b>	
		Sheets Drwg.	Figs. Drwg.
		Print Fig.	
Primary Examiner		Application Examiner	
<b>PREPARED FOR ISSUE</b>			
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>WARNING:</b> The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.	

FILED WITH:

☐ DISK (CRF)

☐ CD-ROM  
(Attached in pocket on right inside flap)